

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Heng Liu
Assignee: BridgeLux, Inc.
Title: Chemical Vapor Deposition Reactor
Application No.: 10/727,746 Filing Date: December 3, 2003
Examiner: Ram N. Kackar Group Art Unit: 1792
Docket No.: M-15626-1D US Confirmation No.: 8880

Irvine, California
February 6, 2009

Via EFS Web Transmission

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO OFFICE ACTION

Dear Sir:

This communication is in response to the non-final Office Action dated October 6, 2008.

Claims begin on page 2.

Remarks begin on page 11.